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Probing the Molecular Conformation of Self-Assembled Monolayers at Metal/ Semiconductor Interfaces by Vibrational Sum Frequency Generation Spectroscopy

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The conformation of self-assembled monolayers (SAMs) buried at metal—semiconductor interfaces plays a crucial role in the functioning of the molecular junctions thus formed. We have studied by vibrational sum frequency generation (SFG) spectroscopy the influence of deposited gold films on the molecular orientation of a series of n-alkyl monolayers that are covalently bonded to silicon(111) via Si—C linkages (≡Si—CnH2n+1, n = 10, 12, 14, and 18). The SFG spectra indicate that the gold contacts (overlayers) introduce significant gauche defects within the initially highly oriented alkyl chains. The methyl tilt angles of the buried n-alkyl monolayers depend on the gold deposition method (vacuum evaporation vs sputtering) and the alkyl chain length. These observations are supported by solid-state electrical measurements.

1. Introduction

Sum frequency generation (SFG) spectroscopy is based on a second-order nonlinear optical effect in which photons are generated at a frequency equal to the sum of the frequencies of the two incident beams.1–4 It is an interface-sensitive technique because the effect is forbidden in media exhibiting inversion symmetry; at a surface or interface such inversion symmetry is necessarily broken. By using visible and tunable infrared input beams, SFG can detect specific vibrations at a buried interface at the time resolution of the laser source. In addition, the polarization combinations of SFG, visible and IR beams can be powerful diagnostic tools for the determination of molecular orientations: the ssp (s-polarized SFG, s-polarized visible, and p-polarized IR) combination detects vibrational modes with dipole moments perpendicular to the interface, the ssp and pss combinations are sensitive to dipole moments parallel to the surface, and the ssp combination responds to both perpendicular and parallel components. The main advantage of SFG spectroscopy, compared with the conventional infrared techniques (FT-IR and Raman), is its capability to reveal the conformation, lateral order, and orientation of surface-bound molecules.5,6 For example, Shen and co-workers have determined that the molecular orientations of pentadecanoic acids at a water surface depend on their surface densities; the monolayer undergoes a transition from the highly disordered “liquid expanded” to the “liquid condensed” phase, for which the alkyl chains are extended toward the air and oriented nearly normal to the water surface.1

SFG spectroscopy has also been adapted to the study of molecular conformations of self-assembled monolayers (SAMs) formed on various substrates.7–16 Two decades ago, Guyot-Sinnest et al. reported that octadecyltrichlorosilane (OTS) monolayers on silica are oriented normal to the surface.8 Hines et al. have shown that alkanethiolate SAMs on gold and silver are relatively more ordered than those prepared on platinum; however, the latter can be “straightened” by applying electrochemical potentials.9 Yeganeh et al. discovered that SFG spectra of alkanethiolate monolayers on a gold(111) surface exhibit an azimuthal angle dependence and attributed this behavior to the binding pattern of the molecules.10 Liu et al. studied the role of water during the adsorption of OTS on a fused silica surface by monitoring conformational changes of the monolayers.11 Recently, Ye et al. examined the orientation of water molecules at the surface of OTS monolayers on quartz under neutral and acidic conditions.12,13 Nishi et al. found that the ratio between CH3 symmetric and asymmetric vibration modes of alkanethiolate SAMs on gold depends on whether the number of carbons is odd or even; this may be due to the difference in the tilt direction of the terminal methyl groups.14

The miniaturization of electronic devices in the past decade has increased the demand for fabricating nanoscale structures, in which organic molecules act as either passive (i.e., tunneling junctions, rectifiers) or active components (i.e., switches, transistors, and logic gates).15 Organic molecules are generally assembled into monolayers whose orientation and conformation play a crucial role in the functioning of the molecular junctions thus formed. Several spectroscopic studies of SAMs at metal/metal or metal/semiconductor interfaces have been reported recently.18-23 While Jun and Zhu developed an attenuated total reflection (ATR) method to probe buried molecular interfaces by IR spectroscopy,20 p-polarized backsidence reflection absorption infrared spectroscopy (p-RAIRS) has been adapted by Richter et al. to the study of the interactions between deposited metal contacts and organic monolayers on silicon surfaces.21 These investigations typically rely on observed peak broadening, frequency shifts, and intensity variations. Hacker et al. have reported the complete disappearance of methylene bands from the IR spectrum of an octadecyl monolayer on silicon upon the deposition of a 5 nm gold film.22

In this work, we explore vibrational SFG spectroscopy as a new technique to probe the molecular orientation of self-assembled monolayers at metal/semiconductor interfaces. The samples were prepared by depositing gold contacts onto alkyl monolayers covalently bonded to silicon surfaces.23,24 We examined not only the effect of the alkyl chain length but also...
the influence of the coating method (thermal evaporation vs sputtering deposition) on the electrical properties of the Au/alkyl monolayer/Si junctions formed. Besides recording changes of various vibrational band frequencies and intensities due to the CH₃ and CH₂ groups, we were able to monitor the Au–CH interactions directly by combining SFG with ATR–IR spectroscopic studies.

2. Experimental Section

2.1. Materials. All chemicals were ACS reagent grade and used as received unless otherwise mentioned. Deionized water (>18.3 Ω·cm) was used throughout the experiments. 1-Decene (94%), 1-dodecene (95%), 1-tetradecene (92%), 1-octadecene (90%), and 1,1,1-trichloroethene (99.5%) were obtained from Morita Chemicals. Ammonium fluoride (40%) was from Morita Chemical Industries. 1-Decene (94%), 1-dodecene (95%), 1-tetradecene (92%), and 1-octadecene (90%) were distilled from sodium under reduced pressure (20–30 Torr), followed by freeze–thaw cycles under vacuum/nitrogen.

2.2. Surface Preparation. Silicon(111) wafers (5–5.0 Ω·cm, n-type, Virginia Semiconductor Inc.) were cut to appropriate size (1.5 × 2 cm) and then cleaned in a “piranha” solution (3:1 mixture of H₂SO₄ and H₂O₂) for 30 min at 90 °C. CAUTION: “Piranha” solution must be handled with extreme care as it reacts violently with organic materials. After copious rinsing with deionized water, the silicon wafers were etched with deoxygenated NH₄F (40% aqueous solution) to remove native oxide and obtain hydrogen-terminated silicon (≡Si–H). The fresh ≡Si–H samples were then introduced under argon into Schlenk tubes containing 2–3 mL of deoxygenated neat 1-alkenes and heated to 160 °C for 4 h. Thus, modified silicon samples (≡Si–CₙH₂n₊₁, n = 10, 12, 14, and 18; abbreviated as C₁₀, C₁₂, C₁₄, and C₁₈, respectively) were cleaned with THF, trifluoroacetic acid solution in THF (1%), and 1,1,1-trichloroethene sequentially and blow-dried with N₂ gas.

Gold deposition on freshly prepared silicon samples was performed via thermal evaporation or sputtering coating. Thermal evaporation was carried out in a vacuum evaporation apparatus (Ulvac, EBH-6). The chamber pressure was lowered to the base pressure of 10⁻⁵ Torr using a diffusion pump; gold (99.99%) was then deposited at a rate of 0.1 nm/s until it reached the film thickness of 10 nm (measured by a calibrated quartz crystal oscillator). Gold sputtering was carried out with a Joel JFC-1200 sputtering coater in an argon-purged chamber under reduced pressure (∼2.0 × 10⁻² Torr). The filament current was kept at approximately 15 mA until the desired film thickness (∼10 nm) was reached. The size of gold contacts was controlled by using an aluminum mask with nine holes (3 mm diameter).

2.3. SFG System. A picosecond Nd:YAG laser (PL2143B, Ekspla) was used to pump an optical parametric generation/optical parametric amplification/difference frequency generation (OPG/OPA/DFG) system to produce tunable infrared radiation (2.3–8.5 μm). The second harmonic output of the YAG (yttrium–aluminum–garnet) laser at 532 nm was used as the visible light source. At the incident angle of 70° for visible and of 50° for infrared light, two beams were loosely focused onto the sample. The [211] direction of Si(111) samples was set in the plane of the incident beams during measurements. The produced SFG signal was filtered through irises and a monochromator (Oriel Instruments, MS257) and amplified by a photomultiplier tube (PMT, Hamamatsu, R3896). All measurements were carried out with p-polarized SFG, visible and IR beams (abbreviated ppp). The SFG signal was normalized to the intensities of the visible and infrared light; all experiments were carried out in air at room temperature (22 ± 2 °C).

The following formulas were used to fit the SFG intensity (I_SFG)

\[ I_{SFG}(\omega_{SFG}) = \omega_{IR} + \omega_{VIS} \propto \left| \chi^{(2)}_{eff} \right|^2 E(\omega_{IR})E(\omega_{VIS})^2 \]

\[ \chi^{(2)}_{eff} = \chi^{(2)}_{NR} + \left( \sum A_n \omega_{IR} - \omega_n + i\Delta \right) \]

where \( \chi^{(2)}_{eff} \) and \( \chi^{(2)}_{NR} \) are the effective second-order nonlinear susceptibilities of the resonant and nonresonant component, respectively, \( \omega_n \) is the phase angle between the resonant and nonresonant component, and \( A_n \) and \( \Delta \) are the amplitude and the homogeneous width of the surface vibration mode (n) corresponding to the frequency \( \omega_n \). On the basis of the above equations, a nonlinear least-squares routine was developed in our laboratory to fit the SFG spectra. The quality of the fit is judged by \( r^2 \) values that were at least 0.900. Specifically, for each vibrational band, the fitting parameters were \( A_n \), \( \omega_{IR} \), and \( \Delta \); while the \( \chi^{(2)}_{NR} \) and \( \phi_n \) were kept constant for the entire spectrum. Another parameter (a constant for flat and a linear term for uneven baselines) was added to adjust the baseline, and this term does not influence the spectral features. Peak intensity ratios were calculated from the amplitudes of individual vibration modes (\( A_n \)). All uncertainties were derived from the spectra of at least three samples.

2.4. Electrical Measurements. The solid-state electrical measurements were carried out with an Autolab electrochemical analyzer (model PGSTAT 30, Eco Chemie BV, The Netherlands). All measurements were performed in a Faraday cage. The contact to the gold pad was made by lowering a tungsten probe with a homemade micropositioning system. The current–voltage (I–V) curves were recorded from +0.5 to −0.5 V at a scan rate of 0.05 V/s. The Mott–Schottky plots (\( C^2 \) vs V) were acquired by scanning the potential from +0.1 to −1.5 V at a frequency of 100 kHz.

2.5. Other Measurements. Wetting measurements were carried out with an AST Optima contact angle system at ambient conditions (18–23 °C, 30–35% relative humidity) using a horizontal light beam to illuminate a 2.0 μL water droplet. Ellipsometric measurements were performed with a Uvisel spectroscopic ellipsometer (Horiba Jobin Yvon) over the range of 300–700 nm at an incident angle of 70°. All reported experimental uncertainties are derived from at least three spots from three independent samples.

3. Results and Discussion

Previous FT-IR spectroscopic studies of self-assembled monolayers (SAMs) at metal/metal (semiconductor) interfaces have provided valuable information regarding metal–molecule interactions, based on the attenuation of certain vibrational modes, peak broadening, or position shifts. For example, Boer et al. proposed that the decrease of the IR peak intensity of the –CH₃ groups of 1-hexadecanethiolate monolayers on gold is due to the Au/Al and CH₃ interactions; Jun and Zhu have suggested that the peak broadening observed for metal/OTS/silicon interfaces is due to monolayer disordering and the peak attenuation due to the cleavage of C–H bonds. These observations may not be simply explained because the dipoles of molecules can be “suppressed” by the metal overlayers, and the roughness of the metal layer may induce scattering of the infrared beam at the metal/molecule interface. There are cases
where new bands arise upon the deposition of metal atoms on top of the organic monolayer; Richter et al. assigned the new peak at ~2825 cm⁻¹ from the metal/OTS/Si system to methylene-metal interactions. Nevertheless, the above-mentioned spectral features are not easily distinguishable as they are typically broad, weak, and sometimes obscured. SFG spectroscopy can provide additional or complementary information to these IR studies, as it is intrinsically sensitive to the interfacial molecular conformation and exhibits submonolayer sensitivity.

### 3.1. Alkyl Monolayers on Silicon

The Si–C-bonded alkyl monolayers were first examined by SFG spectroscopy prior to the metal deposition (Figure 1). All spectra exhibited features that correspond to densely packed and well-oriented monolayers. Specifically, contributions from methylene \((\text{CH}_2)\) stretching modes were negligible, and the spectral features were dominated by the contributions from the methyl \((\text{CH}_3)\) groups: methyl symmetric stretch \((r^+\) at ~2878 cm⁻¹, Fermi resonance \((\text{FR})\) between \(r^+\) and the CH bending overtone at ~2940 cm⁻¹, and the CH₃ asymmetric stretch \((r^-)\) at ~2964 cm⁻¹. These are the features of well-ordered and closely packed molecular monolayers that have the alkyl chains in all-trans configurations. The ellipsometric thickness and the wetting measurements summarized in Table 1 support the above interpretation. The monotonous thickness increase of the C10 to C18 monolayers with the alkyl chain length is in good agreement with values calculated for an average alkyl chain tilt angle of 35° (corresponding to a CH₃ tilt angle of ~70°) (Table 1). The static water contact angles were around 110° for all four monolayer systems, comparable to previous reports for well-packed (intrinsically hydrophobic) alkyl monolayers. ATR–IR studies provide additional evidence (e.g., strong CH₃ asymmetric and symmetric stretching bands) for the high quality of these monolayers.

### 3.2. Alkyl Monolayers at Gold/Silicon Interfaces

Figures 2 and 3 show the SFG spectra of the C10, C12, C14, and C18 monolayers on silicon with deposited gold overlayers. The samples were prepared by thermal evaporation and sputtering deposition. In contrast to Figure 1, the vibrational bands appear as downward peaks due to a phase difference between the nonresonant background (contributed largely from the gold overlayer) and the resonant signal, which is also related to the laser configuration and has been observed for SFG spectra of alkanethiol SAMs on gold. In general, upon gold deposition, strong CH₃ symmetric \((d^+)\) and asymmetric \((d^-)\) peaks appear at ~2850 and ~2920 cm⁻¹. The methylene groups of well-ordered alkyl chains are positioned in a symmetric manner, yet when gauche defects are introduced, such symmetry is broken and the SFG signal arises. Therefore, these new bands indicate that gauche defects in the alkyl chain backbones are introduced upon metal deposition. Independent of the alkyl chain lengths, both thermal evaporation and sputtering deposition of gold contacts disrupt the molecular conformation of the SAMs significantly, as evidenced by the substantial contributions of the methylene bands \((d^+ \text{ and } d^-)\). As shown by the deconvoluted peaks (Figures 2 and 3), methylene contributions relative to methyl peaks are observed to be stronger for samples prepared via sputtering than for those prepared by thermal evaporation; that is, the sputtering method is more destructive. Another important feature of these SFG spectra is the appearance of a new band at ~2900 cm⁻¹. Although \(d^+\) Fermi resonance and several other factors prevent a definite assignment of this band, we have cautiously assigned it to methylene \((\text{CH}_2)\) groups that are interacting with gold, specifically to the CH bonds that are in the proximity of, but not in direct contact with, gold atoms. This means that, upon metal deposition, some regions of the alkyl chains are not directly in contact with gold. It has been suggested that gold will

### Table 1: Thickness and Wetting Measurements of Alkyl Monolayers on Silicon

<table>
<thead>
<tr>
<th>Sample</th>
<th>H₂O Contact Angle/°</th>
<th>(d_{\text{calc}}/\AA)</th>
<th>(d_{\text{calc}}/\AA^\prime)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Si–(CH₃)₂CH₃ (C10)</td>
<td>109 ± 2</td>
<td>12.8 ± 1.0</td>
<td>11.4</td>
</tr>
<tr>
<td>Si–(CH₃)₃CH₂ (C12)</td>
<td>108 ± 3</td>
<td>14.0 ± 1.2</td>
<td>13.5</td>
</tr>
<tr>
<td>Si–(CH₃)₄CH₂ (C14)</td>
<td>109 ± 2</td>
<td>15.4 ± 1.1</td>
<td>15.7</td>
</tr>
<tr>
<td>Si–(CH₃)₅CH₂ (C18)</td>
<td>106 ± 2</td>
<td>20.4 ± 1.3</td>
<td>20.0</td>
</tr>
</tbody>
</table>

* The predicted monolayer thickness was calculated from the equation \(d = 1.86 + 1.30(n - 1)\cos \theta\), where \(d\) is the thickness, \(n\) is the number of carbons in the alkyl chain, and \(\theta\) is the angle between the molecule axis and the surface normal. An average tilt angle, \(\theta = 35°\), was used to calculate the thickness of each alkyl monolayer.

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**Figure 1.** SFG spectra of (a) Si–(CH₃)₂CH₃ (C10), (b) Si–(CH₃)₃CH₂ (C12), (c) Si–(CH₃)₄CH₂ (C14), and (d) Si–(CH₃)₅CH₂ (C18). The solid lines (in black) show the best fits to the experimental data (open circles) based on eqs 1 and 2; the deconvoluted peaks are shown in red at the bottom (see the main text for details).
completely penetrate n-alkyl monolayers; our SFG results show that, at least at the submonolayer scale, gold penetration does occur in a “patchy” manner.

Techniques such as FT-IR spectroscopy and time-of-flight secondary ion mass spectrometry (TOF-SIMS) have helped to detect molecules and determine their chemical identities at buried interfaces. The present SFG investigations also provide further insights into molecular orientations. It is clear that the originally highly oriented alkyl chains have become disordered, but the observed strong methyl stretching bands indicate that the organic monolayers are still relatively ordered after the formation of metal contacts to the top.

This is seemingly different from the case reported by Haick et al. in which the metal evaporation damaged the molecules and the decomposition products did not remain at the interface. Hacker et al. also described the displacement of an entire monolayer detected by p-polarized backside reflection absorption infrared spectroscopy (pb-RAIRS). It should be noted that Haick et al. studied monolayers on GaAs, and Hacker et al. prepared their Si–C-bonded 1-octadecyl (C18) monolayer with a 10 mM solution of 1-octadecene. This may account for the observed differences. Our STM studies and ATR–IR spectroscopic measurements also showed significant differences in the morphology of the gold contacts and in the packing/molecular orientation. Although it is difficult at this stage to conclusively determine the cause of the discrepancies, our results generally support the conclusion drawn by Hacker et al. that the deposited gold atoms penetrate the monolayer and directly contact the underlying silicon.

3.3. Effect of Metal Deposition Method. To provide further insights into how different metal coating methods influence the molecular conformation of SAMs at buried interfaces, the
The intensity ratio of the methyl symmetric and asymmetric stretches $A_q(r^-)/A_q(r^+)$ was used to estimate the average tilt angle using the following equation: \(^{38-40}\)

$$\frac{A_q(r^-)}{A_q(r^+)} = \frac{\beta_{\text{total}}}{\beta_{\text{ave}}} \times \frac{(2F_{zzz} - F_{xxz})}{F_{xxz} + \frac{1}{2}F_{xzx}(1 + r)} \cos \theta - \cos^3 \theta$$

(3)

In eq 3, $\theta$ is the angle between the main axis of the methyl group and the surface normal; $F_{zzz}$ and $F_{xxz}$ are combinations of the Fresnel factors for the SFG, visible, and IR beams; $\beta$ is the hyperpolarizability; and $r$ is the $\beta_{\text{total}}/\beta_{\text{ave}}$ ratio (equal to 0.25). The ratio $\beta_{\text{total}}/\beta_{\text{ave}}$ has a value of 4.21.41 This model can be applied to the C$_3$ symmetry for the methyl groups under the assumption that the $zzz$ and $xxz$ susceptibility elements dominate the SFG signal (for gold/silicon interfaces).42

$$F_{zzz} > > F_{xzr} = F_{xxxx}$$

(4)

Therefore, the tilt angle determination using eq 3 is not applicable to the silicon substrate; it is only valid after deposition of gold that significantly enhances the electric field of the z component. Rather than a particular or an averaged tilt angle, it is more realistic to estimate the range for each monolayer system. Generally, a Gaussian distribution can be assumed to model the methyl orientation angles (see the Supporting Information).43-45

$$f(\theta) = C \exp[-(\theta - \theta_0)^2/2\sigma^2]$$

(5)

In eq 5, $\theta_0$ is the mean orientation angle, $C$ is a normalization constant, and $\sigma$ is the root-mean-square width. For a direct comparison, thus obtained methyl tilt angles for alkyl monolayers at gold/silicon interfaces are summarized in Table 2.

The average tilt angles of the alkyl chains in alkyl monolayers on silicon have been reported to be $35-40^\circ$,12,24,42 which corresponds to methyl tilt angles of $70-75^\circ$. This means that the alkyl chains become less tilted; that is, they “stand up” from the surface upon metal deposition (Table 2). The absolute tilt angles are difficult to determine due to gauche defects and the wide range of possible orientations. Focusing on the differences between the two gold deposition methods, as shown in Table 2, the methyl tilt angles for the samples prepared via thermal evaporation are much smaller than those prepared by sputtering.

**TABLE 2:** Estimated Methyl Tilt Angles ($\theta$) of Alkyl Monolayers at Gold/Silicon Interfaces; the Range Was Based on the Assumption of Gaussian Distributions (See Text for Details)

<table>
<thead>
<tr>
<th>sample</th>
<th>$A(r^-)/A(r^+)$</th>
<th>tilt angles</th>
</tr>
</thead>
<tbody>
<tr>
<td>thermal evaporation</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Si-$(\text{CH}_2)_n\text{CH}_3$ (C10)</td>
<td>2.6 ± 0.3</td>
<td>18-28°</td>
</tr>
<tr>
<td>Si-$(\text{CH}_2)_n\text{CH}_3$ (C12)</td>
<td>2.6 ± 0.4</td>
<td>18-28°</td>
</tr>
<tr>
<td>Si-$(\text{CH}_2)_n\text{CH}_3$ (C14)</td>
<td>2.5 ± 0.2</td>
<td>18-28°</td>
</tr>
<tr>
<td>Si-$(\text{CH}_2)_n\text{CH}_3$ (C18)</td>
<td>2.4 ± 0.3</td>
<td>18-28°</td>
</tr>
<tr>
<td>sputtering</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Si-$(\text{CH}_2)_n\text{CH}_3$ (C10)</td>
<td>5.7 ± 0.7</td>
<td>62-80°</td>
</tr>
<tr>
<td>Si-$(\text{CH}_2)_n\text{CH}_3$ (C12)</td>
<td>4.4 ± 0.4</td>
<td>46-66°</td>
</tr>
<tr>
<td>Si-$(\text{CH}_2)_n\text{CH}_3$ (C14)</td>
<td>4.1 ± 0.6</td>
<td>41-49°</td>
</tr>
<tr>
<td>Si-$(\text{CH}_2)_n\text{CH}_3$ (C18)</td>
<td>3.3 ± 0.7</td>
<td>33-36°</td>
</tr>
</tbody>
</table>

**SCHEME 1:** Hypothetical View of Monolayer–Metal Interactions during Gold Deposition via (a) Thermal Evaporation and (b) Sputtering Deposition
energy of condensing gold atoms (~0.27 eV). Thermal expansion of the monolayer will be minimized in this case because the source is kept cold; however, the high kinetic energies allow the metal atoms to penetrate the monolayers more readily than in the thermal evaporation process (Scheme 1, b1). The different tilt angles upon sputtering gold on top of alkyl monolayers on silicon indicate that the monolayers respond to the bombardment with high-energy gold atoms differently. Although a short-chain monolayer (i.e., C10) will simply maintain its original tilt angle, the longer alkyl chains may be reoriented upon metal penetration. As the gaps between molecules are occupied slowly by metal atoms, the molecules gradually stand up. The affinity of methylene groups for gold atoms has been demonstrated previously; thus, longer alkyl chains will limit the mobility of gold atoms within the monolayer.

3.4. Electrical Measurements. It is evident that both deposition methods result in gold penetration into the monolayers and induce gauche defects within alkyl-chain backbones (Scheme 1). However, the structural deformation of the organic monolayers at the buried interfaces differs significantly, as suggested by the above SFG investigations. The structural differences are also reflected in the electrical properties of thus formed Au/alkyl monolayer/Si junctions. Figure 4 shows typical current density (J) versus bias voltage (V) plots. All samples prepared via thermal deposition exhibited clear rectifying behavior (Figure 4a). The effective barrier heights and ideality factors were determined based on the thermionic emission model (see the Supporting Information) and are summarized in Table 3. The average values of $q_{\phi_{\text{eff}}}$ for the four monolayer systems are slightly different; that is, a marginal increase was observed for C10–C14, but the value dropped for C18. Such an insignificant increase may be due to the depth (extent) of gold penetration being dependent on the monolayer thickness. The drop in $q_{\phi_{\text{eff}}}$ for the C18 monolayer can be explained by its lower packing density, as indicated by the smaller water contact angle (106 ± 2°). It is important to note that most of the $q_{\phi_{\text{eff}}}$ values were within the experimental uncertainties. We have shown previously that there is no dependence on the alkyl chain length when the monolayers are prepared via an organometallic route (i.e., identical to an Au/H–Si junction). In addition, the rather large uncertainties compared with those previously reported for Hg/alkyl monolayer/Si junctions indicate the uneven lateral gold penetration. This is consistent with our SFG observations; that is, there are C–H groups that are not in direct contact with the gold atoms.

In contrast, the junctions prepared via sputtering deposition were less rectifying and the current densities clearly different when the chain length was varied (Figure 4b). The semilog J–V curve for C10 is symmetric, which means that such a junction is essentially an Ohmic contact. As the chain length increases, the rectifying behavior becomes more prominent (i.e., the current at forward bias becomes much higher than that at the reversed bias). In principle, a direct Au/Si junction should be rectifying, as shown in our previous report. The Ohmic behavior of the Au/H–Si contact has been previously observed by scanning tunneling microscopy (STM) and attributed to the induced surface states in the band gap region as a result of direct bonding between gold and silicon. The Ohmic behavior of sputtered samples indicates strong interactions between gold atoms and the silicon substrates; that is, high-energy gold atoms penetrate the monolayers and attack the silicon surface, possibly with shallow penetration into the silicon bulk. It is interesting to note that, although the penetration occurs to a greater extent, the alkyl chains stay intact and relatively well-oriented. Gold atoms are not displacing the surface silicon atoms since such damage would cause a dislocation of the monolayer. As the chain length increases, the degree of gold penetration seems to decrease; however, it is more significant than in thermal evaporation where all junctions showed clear rectifying behavior. This result supports the SFG data, suggesting that metal penetration occurs at a slower rate for the longer alkyl chains (reflected by the difference in the tilting angles of the buried monolayers). The loss of a clear Au–(molecule)–Si interface was also supported by the fact that linear Mott–Schottky (M–S) curves were not obtained for sputtered samples, whereas for samples prepared via thermal evaporation, the M–S plots were linear over a large potential range (Figure 5), an indication of intact silicon substrates. In particular, the doping density ($N_d$) and built-in potential at zero bias (V_{bi}) estimated from M–S plots (Table 3), are in good agreement with previously reported data.
junctions; the gold contacts were prepared via thermal evaporation.

sputtering) affects the monolayer structure at the buried interface.

probe the molecular order of organic monolayers at buried metal/semiconductor interfaces. Gold penetration induces gauche

4. Conclusion

We have shown that SFG spectroscopy is a powerful tool to probe the molecular order of organic monolayers at buried metal/semiconductor interfaces. Gold penetration induces gauche defects to the alkyl monolayers prepared on silicon, but the monolayers surprisingly maintain relatively ordered configurations. The method of gold deposition (thermal evaporation vs sputtering) affects the monolayer structure at the buried interface. The average tilt angle of methyl groups was similar (~28°) for all samples prepared via thermal evaporation, whereas for the sputtered samples, chain-length dependence was evident. In both cases, the monolayers seem to “stand up” upon gold deposition; for the thermal evaporation, this can be explained by the “heating effect” of the radiation source. The sputtering process induces more permanent damage and disordering to the alkyl monolayers; thus formed junctions even lose the rectifying property as a result of strong interactions between gold atoms and the silicon substrate.

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Supporting Information Available: Experimental results of ATR–FTIR and solid-state electrical measurements. This material is available free of charge via the Internet at http://pubs.acs.org.

References and Notes


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